



## Sheet 1 Semiconductor Review

T=300	Si	Ge	GaAs
$n_i$ (cm <sup>-3</sup> )	$1.45 \times 10^{10}$	$2.4 \times 10^{13}$	$1.8 \times 10^6$
$\mu_n$ (cm <sup>2</sup> /Vs)	1500	3900	8500
$\mu_p$ (cm <sup>2</sup> /Vs)	450	1900	400

### Problem 1

- Explain qualitatively the differences in intrinsic carrier concentrations ( $n_i$ ) for Ge, Si and GaAs. (Why is  $n_i$  highest for Ge? Why is it lowest for GaAs?)
- Explain qualitatively why  $n_i$  increases with increasing temperature.

### Problem 2

Consider a Si sample under equilibrium conditions, doped with Boron to a concentration  $10^{17}$  cm<sup>-3</sup>.

- At  $T = 300\text{K}$ , is this material n-type or p-type?
- What are the majority and minority carrier concentrations?

### Problem 3

Consider a Si sample maintained at  $T = 300\text{K}$  under equilibrium conditions, doped with Boron to a concentration  $2 \times 10^{16}$  cm<sup>-3</sup>:

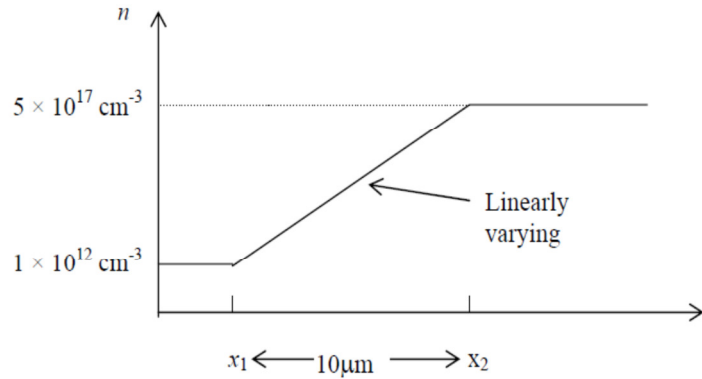
- What are the electron and hole concentrations ( $n$  and  $p$ ) in this sample? Is it n-type or p-type?
- Suppose the sample is doped additionally with Phosphorus to a concentration  $6 \times 10^{16}$  cm<sup>-3</sup>. Is the material now n-type or p-type? What is the resistivity of this sample?

#### **Problem 4**

Ultra-thin semiconductor materials are of interest for future nanometer-scale transistors, but can present undesirably high resistance to current flow. How low must the resistivity of a semiconductor material be, to ensure that the resistance of a 2nm-thick, 10nm-long, 100nm-wide region does not exceed 100 ohms? If this material is n-type Si, estimate the dopant concentration that would be needed to achieve this resistivity.

#### **Problem 5**

A silicon sample maintained at 300 K under thermal equilibrium has a non-uniform doping concentration profile, such that the electron concentration,  $n$ , varies linearly from  $1 \times 10^{12} \text{ cm}^{-3}$  to  $5 \times 10^{17} \text{ cm}^{-3}$  while going from point  $x_1$  to point  $x_2$ . Assume that the mobility is constant at  $1000 \text{ cm}^2/\text{Vs}$  throughout the sample.



- Calculate the diffusion coefficient,  $D_n$  (in  $\text{cm}^2/\text{s}$ ) for the electrons
- Plot the diffusion current density ( $\text{A}/\text{cm}^2$ ) for the electrons as a function of  $x$ . Mark the numerical value on the graph. (Hint: What is the equation for diffusion current density?)